

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L3	70	1 and third adj (wafer or substrate)	US-PGPUB; USPAT	OR	ON	2005/01/22 10:05
L2	474	1 and third with (wafer or substrate)	US-PGPUB; USPAT	OR	ON	2005/01/22 10:05
L1	1976	((438/113) or (438/456) or (438/458) or (438/460)).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/01/22 10:04
S59	0	S58 and (third adj (wafer or substrate))	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/21 15:19
S58	372	(438/for.386).CCLS.	EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/01/21 15:18
S57	0	(438/for.386).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/01/21 15:18
S1	162	(438/456).CCLS.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/01/21 15:18
S56	70	((438/113) or (438/456) or (438/458) or (438/460)).CCLS.) and third adj (wafer or substrate)	US-PGPUB; USPAT	OR	ON	2005/01/21 15:08
S49	65	((438/113) or (438/456) or (438/458) or (438/460)).CCLS.) and third adj (wafer of substrate)	US-PGPUB; USPAT	OR	ON	2005/01/21 15:07